(c) depositing said amorphous particles onto a support; and

(d) either essentially simultaneously with said deposition or subsequently thereto consolidating said deposit of amorphous particles into a non-porous body;

the improvement comprising utilizing as said silicon-containing compound in vapor form, a halide-free polymethylcyclosiloxane selected from the group consisting of octamethylcyclotetrasiloxane, decamethylcyclopentasiloxane, hexamethylcyclotrisiloxane, and mixtures thereof, whereby no halide-containing vapors are emitted during the making of said non-porous body of high purity fused silica glass.

45. (Amended) In a method for making a non-porous body of high purity fused silica glass doped with at least one oxide dopant comprising the steps of:

- (a) producing a gas stream containing a silicon-containing compound in vapor form capable of being converted through thermal decomposition with oxidation or flame hydrolysis to SiO₂ and a halide-containing compound in vapor form capable of being converted through oxidation or flame hydrolysis to at least one member of the group consisting of P₂O₅ and a metal oxide which has a metallic component selected from Group IA, IB, IIA, IIB, IIIA, IIIB, IVA, IVB, VA, and the rare earth series of the Periodic Table;
- (b) passing said gas stream into the flame of a combustion burner to form amorphous particles of fused SiO₂ doped with an oxide dopant;
 - (c) depositing said amorphous particles onto a support; and
- (d) either essentially simultaneously with said deposition or subsequently thereto consolidating said deposit of amorphous particles into a non-porous body; the improvement comprising utilizing as said silicon-containing compound in vapor form a halide-free polymethylcyclosiloxane, whereby no halide-containing vapors from said silicon-containing compound are emitted during the making of said non-porous body of high fused silica glass.

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- 48. (Amended) In a method for making optical waveguide fibers of high purity fused silica glass doped with an oxide dopant comprising the steps of:
- (a) producing a gas stream containing a silicon-containing compound in vapor form capable of being converted through thermal decomposition with oxidation or flame hydrolysis to SiO₂ and a halide containing compound in vapor form capable of being converted through oxidation or flame hydrolysis to at least one member of the group consisting of P₂O₅ and a metal oxide which has a metallic component selected from Group IA, IB, IIA, IIB, IIIA, IIIB, IVA, IVB, VA, and the rare earth series of the Periodic Table;
- (b) passing said gas stream into the flame of a combustion burner to form amorphous particles of fused SiO₂ doped with an oxide dopant;
 - (c) depositing said amorphous particles onto a mandrel;
- (d) consolidating said deposit of amorphous particles into a non-porous transparent glass body; and
- (e) drawing waveguide fiber from said body; the improvement comprising utilizing as said silicon-containing compound in vapor form a halide-free polymethylcyclosiloxane, whereby no halide-containing vapors from said silicon-containing compound are emitted during the making of said optical waveguide fibers.
- 29. (Amended) In a method of making high purity fused silica glass through the outside vapor deposition process comprising the steps of:
- (a) producing a gas stream containing a silicon-containing compound in vapor form capable of being converted through thermal decomposition with oxidation or flame hydrolysis of SiO₂;
- (b) passing said gas stream into the flame of a combustion burner to form amorphous particles of fused SiO₂;
 - (c) depositing said amorphous particles onto a mandrel; and
- (d) consolidating said deposit of amorphous particles into a non-porous, transparent glass body;

the improvement comprising utilizing as said silicon-containing compound in vapor form a halide-free polymethylcyclosiloxane selected from the group consisting of octamethylcyclotetrasiloxane, decamethylcyclopentasiloxane, hexamethylcyclotrisiloxane, and mixtures thereof, whereby no halide-containing

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vapors from said silicon-containing compound are emitted during the making of said high purity fused silica glass.